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1	APPLICATION NO. FILING D 10/632,582 67/31/2		DATE FIRST NAMED INVENTOR		ATTORNEY DOCKET NO.	CONFIRMATION NO.
			/2003	Ban Gavish	42P10059CD	5004
	8191	7590	0 1/23/2004		EXAM	INER
	12400 WILS	HIRE BOULE	TAYLOR & 2 VARD, SEVEN	AFMAN TH FLOOR	HASSANZADEH, PARVEZ	
	LOS ANGELES, CA 90025				ART UNIT	PAPER NUMBER

DATE MAILED 01/23/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s) GAVISH ET AL.				
Office Action Summar	10/632,582					
Office Action Summary	Examiner	Art Unit				
	Parviz Hassanzadeh	1763				
Period for Reply	nunication appears on the cover sheet w	ith the correspondence address				
If the period for reply specified above is less than the ITNO period for reply is specified above, the maximum. Failure to make within the relief above.	sions of 37 CFR 1,138(a). In no event, however, may a communication. He will be storotory minimum of this in database; period will apply and will expire SIX (6) MOV httply will, by statute, cause the application to become Al	ty (30) days will be considered timely. (THS from the mailing date of this communication				
1)⊠ Responsive to communication(s) filed on <u>02 September 2003</u> .						
2a) This action is FINAL.	2b)⊠ This action is non-final.					
 Since this application is in condit closed in accordance with the principle. 	ion for allowance except for formal matt actice under Ex parte Quayle, 1935 C.D.	ers, prosecution as to the merits is				
Disposition of Claims	an parto dotaylo, 1955 C.D	. 11, 400 O.G. 213.				
4)⊠ Claim(s) 1-12 is/are pending in the	e application					
4a) Of the above claim(s)i 5) Claim(s) is/are allowed.	s/are withdrawn from consideration.					
6) Claim(s) <u>1-12</u> is/are rejected.						
7) Claim(s) is/are objected to						
8) Claim(s) are subject to res	triction and/or election requirement.					
Application Papers						
9) The specification is objected to by	the Examiner.					
10) The drawing(s) filed on is/a	re: a) accepted or h) objected to b	or the Francisco				

- is/are: a) accepted or b) objected to by the Examiner.
- Applicant may not request that any objection to the drawing(s) be held in abevance. See 37 CFR 1.85(a).

Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. §§ 119 and 120

- 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some c) None of:
 - Certified copies of the priority documents have been received.

 Certified copies of the priority documents have been received in Application No.
 - 3. Copies of the certified copies of the priority documents have been received in this National Stage
- application from the International Bureau (PCT Rule 17,2(a)). * See the attached detailed Office action for a list of the certified copies not received.
- 13) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application)
 - since a specific reference was included in the first sentence of the specification or in an Application Data Sheet. a) The translation of the foreign language provisional application has been received.
- 141 Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121 since a specific reference was included in the first sentence of the specification or in an Application Data Sheet, 37 CFR 1.78.

Attachment(s)		
Notice of References Ched (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Notice of Draftsperson's Patent Drawing Review (PTO-948) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Interview Summary (PTO-413 Notice of Informal Patent App Other	i) Paper No(s) fication (PTO-152)

Application/Control Number: 10/632,582 Art Unit: 1763

DETAILED ACTION

Specification

The disclosure is objected to because of the following informalities: it is suggested to update the information on the related applications recited on page 1, for example, the application with serial No. 10/209,983 is now US Patent No. 6,627,538 B2.

Appropriate correction is required.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patter may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior ast are such that the adopter matter as a whole would have been obvious at the time the mension was made to an area sharing ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manteer making the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the craminer presumes that the subject master of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contarty. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 103(c), (10 or (a) prior at under 35 U.S.C. 103(c) and potential 35 U.S.C. 103(c), (10 or (a) prior at under 35 U.S.C. 103(c)).

Claims 1-12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ohnishi et al (US Patent No. 5,120,925) in view of Drummond et al (US Patent No. 5,132,248).

Ohnishi et al teach a system (Figs. 2, 3) comprising:

a chamber housing a substrate 200;

an ion beam 100 (energy source) coupled to the chamber:

a system controller 550 to control introduction of metal precursor gas 110 to a focus ion beam 1 and to control the ion beam generating unit, wherein the computer 500 includes a memory having computer-readable program for controlling the operation of the system.

Ohnishi et al fail to teach a coherent electromagnetic radiation source to heat a metal layer formed on the substrate.

Drummond et al teach an apparatus for forming a metal deposition on the surface of a substrate, wherein the metal layer on the substrate is annealed by a radiation light source such as a laser source (Fig. 1; column 3, lines 65-68; column 5, lines 27-37).

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to implement the laser source as taught by Drummond et al in the system of Ohnishi et al in order to anneal the metal film formed on the substrate.

Further regarding claims 2, 3, 8-10: The type of the metal, the chamber pressure, and the thickness of the formed layer are considered process limitation rather than structural limitations and the apparatus as discussed above is capable of being used for forming, for example, platinum under the condition recited in the claims.

The particular type of gas used is a process limitation rather than an apparatus limitation, and the recitation of a particular type of gas does not limit an apparatus claim, see In re Casey.

152 USPQ 235; In re Rishol, 94 USPQ 71; In re Young. 25 USPQ 69; In re Dulburg. 129 USPQ 348; Ex parte Thibault, 64 USPQ 666; and Ex parte Masham, 2 USPQ2d 1647. This rejection is based on the fact the apparatus structure taught by prior art has the inherent capability of being used in the manner intended by the Applicant. When a rejection is based on the inherency, a

rejection under 35 U.S.C. 102 or U.S.C. 103 is appropriate. (See *In re Fitzgerald* 205 USPQ 594 or MPEP 2112)

It has been held that claims directed to apparatus must be distinguished from the prior art in terms of structure rather than function. In re Danley, 120 USPQ 528, 531, (CCPQ 1959);

"Apparatus claims cover what a device is, not what a device does" (Emphasis in original)

Hewlest-Packard Co. V. Bausch & Lomb Inc., 15USPQ2d 1525, 1528 (Fed. Cir. 1990); and a claim containing a "recitation with respect to the manner in which a claimed apparatus is intended to be employed dos not differentiate the claimed apparatus from a prior art apparatus" if the prior art apparatus teaches all the singuistral limitations of the claim Exparte Masham, 2

USPQ2d 1647 (Fd. Pat. App. & Inter. 1987). Also see MPEP 2114.

Further regarding claims 4-7: The ion beam taught by Ohnishi et al is a focus ion beam and thus would inherently heat a discrete area on the layer; the radiation source as taught by Drummond et al is preferably a laser source including laser optics for focusing the laser to a spot size on the layer. Further, the selection of an appropriate lens for the laser radiation is considered to have been obvious to one of ordinary skill in the art at the time of the invention in order to focus the radiation to a desired spot size.

Further regarding claims 11, 12: It is held in re Harza, 274 F:2d 669, 124 USPQ 378 (CCPA 1960) that a mere duplication of parts has no patentable significance unless a new and unexpected result is produced therefore it would have been obvious to one of ordinary skill in the art at the time the invention was made to include a plurality of metal precursor gases in order to introduce different metal precursor gases into the chamber separately or simultaneously as desired.

Double Patenting

The nonstantory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See In re Goodman, 11 F.3d 1046, 29 USPQC2d 2010 (Fed. 1993); In re long, 759 F.2d 887, 722 USPQ-64 Fed. Cir. 1985); In re Para Orman, 686 F.2d 937, 214 USPQ 610 (CCPA 1982); In re Vogel, 422 F.2d 438, 164 USPQ 619 (CCPA 1970); and, In re Thornisgon, 418 F.4d 258, 163 USPQ 644 (CCPA 1964).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application. See 37 CFR 1.130(b).

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

Claims 1-12 are provisionally rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1-6 of copending Application No. 10209;453. Although the conflicting claims are not identical, they are not patentably distinct from each other because the structural limitations in both cases are obvious and similar variation of each other.

This is a <u>provisional</u> obviousness-type double patenting rejection because the conflicting claims have not in fact been patented.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

Tao et al (US Patent No. 5,104,684) teach an ion beam metal deposition system;

Azuma et al (US Patent No. 5,976,328) teach an ion beam processing system wherein the surface of a metal film is heated by a radiation source (column 7, lines 24-68).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Parviz Hassanzadeh whose telephone number is (571)272-1435. The examiner can normally be reached on Tuesday-Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory Mills can be reached on (703)308-1633. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)308-0661.

P. Hassenzodek Parviz Hassanzadeh Primary Examiner Art Unit 1763

December 30, 2003